

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	54	komada-daisuke-.in. komada-d-.in. katamu-katsumi-.in. katamu-k-.in.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/19 14:56
L2	14	komada-daisuke-.in. komada-d-.in. katamu-katsumi-.in. katamu-k-.in.	US-PGPUB; USPAT	OR	ON	2005/12/19 14:56
L3	140428	sic (silicon adj carbide)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/19 14:57
L4	313	(hydrogenated near (siC! silicon adj carbide))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/19 14:57
L5	21801	sf6 "sf.sub.6" nf3 "nf.sub.3"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/19 15:18
L6	59711	fluorocarbon hydrofluorocarbon	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/19 15:18
L8	23325	cf4 "cf.sub.4" carbon adj tetrafluoride	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/19 15:32
L9	12888	ch?f? "cf.sub.? f.sub.?"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/19 15:32
L10	8082	nitrogen adj trifluoride sulfur adj hexafluoride	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/19 15:32
L11	52	sixcyhz "si.sub.x c.sub.y h.sub.z" si?c?h? "si.sub.? c.sub.? h.sub.?"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/19 15:40
L12	9	(3 4 11) near4 etch\$4 near4 (6 8 9) near4 (5 10)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/19 15:53
L13	46	(3 4 11) with etch\$4 with (6 8 9) with (5 10)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/19 15:58
L16	3	((3 4 11) same etch\$4 same (6 8 9) same (5 10)).clm.	US-PGPUB	OR	ON	2005/12/19 15:59

L17	181156	(insulating insulator dielectric) near (layer coating film)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/19 16:13
L18	844011	resist photoresist photo-resist photosensitive photo-sensitive (sensitive near (photo light energy radiation))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/19 16:13
L20	10	(17 same 18 same (3 4 11)).clm.	US-PGPUB	OR	ON	2005/12/19 16:47
L22	0	(17 same (6 8 9) same (5 10) same (3 4 11)).clm.	US-PGPUB	OR	ON	2005/12/19 16:47